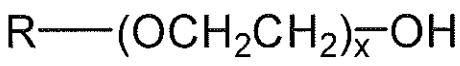
POLISHING SLURRY COMPOSITION

ABSTRACT OF THE DISCLOSURE

Provided is a polishing slurry composition, including a non-ionic surfactant represented by the following formula (1)



formula (1)

wherein x is an integer from 1 to 50.